

Correction

Correction: Guo, Q.; et al. Comparison of *in Situ* and *ex Situ* Methods for Synthesis of Two-Photon Polymerization Polymer Nanocomposites. *Polymers* **2014, *6*, 2037–2050**

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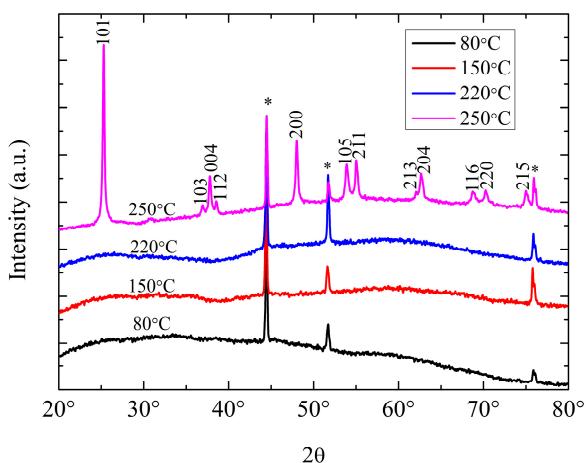
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The authors wish to make the following corrections to this paper [1]. In Figure 4, the unit of CuK α radiation is Å, not μm. The caption of Figure 4 should read: XRD patterns of pure TiO₂ nanoparticles heat-treated at 80 °C, 150 °C, 220 °C, and 250 °C were obtained by using CuK α radiation at $\lambda = 1.5406 \text{ \AA}$.

Figure 4. XRD patterns of pure TiO₂ nanoparticles heat-treated at 80 °C, 150 °C, 220 °C, and 250 °C were obtained by using CuK α radiation at $\lambda = 1.5406 \text{ \AA}$. (*) shows substrate Incubo peak.



Reference

1. Guo, Q.; Ghadiri, R.; Weigel, T.; Aumann, A.; Gurevich, E.L.; Esen, C.; Medenbach, O.; Cheng, W.; Chichkov, B.; Ostendorf, A. Comparison of *in Situ* and *ex Situ* Methods for Synthesis of Two-Photon Polymerization Polymer Nanocomposites. *Polymers* **2014**, *6*, 2037–2050.

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